



제 30회 한국반도체학술대회

The 30th Korean Conference on Semiconductors

2023년 2월 13일(월)~ 15일(수) | 강원도 하이원리조트(그랜드호텔 컨벤션타워)

2023년 2월 15일(수), 09:00-10:30

Room E (루비 II, 5층)

E. Compound Semiconductors 분과 [WE1-E] Compound Semiconductor I

좌장: 임유승 교수(세종대학교)

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| <p>WE1-E-1 09:00-09:15</p> | <p>Record In_{0.8}Ga_{0.2}As Quantum-well HEMTs for 6G Applications Wan-Soo Park¹, Hyeon-Bhin Jo¹, Hyo-Jin Kim¹, Su-Min Choi¹, Ji-Hoon Yoo¹, Hyeon-Seok Jeong¹, Takuya Tsutsumi², Hiroki Sugiyama², Hideaki Matsuzaki², Jae-Hak Lee¹, and Dae-Hyun Kim¹ ¹School of Electronic and Electrical Engineering, Kyungpook National University, ²NTT Device Technology Laboratories</p> |
| <p>WE1-E-2 09:15-09:30</p> | <p>High-speed and Low-voltage Operating Charge Trap Device based on InGaAs TFETs for Low-power Neuromorphic Application Dae-Hwan Ahn¹, Suman Hu^{1,2}, Kyeol Ko¹, Donghee Park¹, Hoyung Suh¹, Gyu-Tae Kim², Jae-Hoon Han¹, Jin-Dong Song¹, and Yeon Joo Jeong¹ ¹KIST, ²Korea University</p> |
| <p>WE1-E-3 09:30-09:45</p> | <p>Explicit Thermal Resistance Model of Self-heating Effects of AlGaIn/GaN HEMTs with Linear and Non-linear Thermal Conductivity Surajit Chakraborty¹, Walid Amir¹, Ju-Won Shin¹, Ki-Yong Shin¹, Takuya Hoshi², Takuya Tsutsumi², Hiroki Sugiyama², Hideaki Matsuzaki², and Tae-Woo Kim¹ ¹Department of Electrical, Electronic and Computer Engineering, University of Ulsan, ²NTT Device Technology Laboratories, NTT Corporation</p> |
| <p>WE1-E-4 09:45-10:00</p> | <p>Investigation for Spatial Distribution of Oxide Trap Density by Low-Frequency Noise Characterization in β-Ga₂O₃ FinFET Jae Wook Yoo¹, Hong Seung Lee¹, Hyeon Jun Song¹, Seongbin Lim¹, Jungsik Kim⁴, Kihyun Kim¹, Jun-Young Park³, Yang-Kyu Choi², and Hagyoul Bae¹ ¹Jeonbuk National University, ²KAIST, ³Chungbuk National University, ⁴Gyeongsang National University</p> |
| <p>WE1-E-5 10:00-10:15</p> | <p>Full Stepper-Based InP Double-Heterojunction Bipolar Transistors (DHBTs) with f_T & $f_{max} \geq 250$ GHz Hyeon-Seok Jeong^{1,2}, Yong-Hyun Kim¹, Jacob Yun¹, Ji-Min Beak², Ji-Hoon Yoo², Su-Min Choi², Wan-Soo Park², Hyo-Jin Kim², In-Geun Lee², Ted Kim¹, Jae-Hak Lee², Hyuk-Min Kwon³, Seung Heon Shin³, and Dae-Hyun Kim² ¹QSI Inc., ²Kyungpook National University, ³Korea Polytechnics</p> |
| <p>WE1-E-6 10:15-10:30</p> | <p>5-levels-stacked In_{0.53}Ga_{0.47}As MBCFETs with Regrown S/D Contacts In-Geun Lee¹, Hyeon-Bhin Jo¹, Ji-Hoon Yoo¹, Hyunchul Jang², Minwoo Kong², Hyeon-Seok Jeong¹, Wan-Soo Park¹, Sang-Kuk Kim³, Jae-Gyu Kim³, Jacob Yun³, Ted Kim³, Jae-Hak Lee¹, Chan-Soo Shin², Kwang-Seok Seo², and Dae-Hyun Kim¹ ¹Kyungpook National University, ²KANC, ³QSI Inc.</p> |